



LIST OF PATENTS AND PUBLICATIONS APPLICANT'S INFORMATION DISCLOSURE STATEMENT (Form PTO-1449)	Attorney Docket: 101769-301-WCG	Serial No. TBA (International Application No. PCT/EP03/01833)
	Applicant: Marc HUSEMANN, et al.	
	Filing Date: March 28, 2005 (International Filing Date February 24, 2003)	Group: TBA

U.S. PATENT DOCUMENTS

Examiner's Initial	Document Number	Date	Name	Class	Sub Class	Filing Date If appropriate
/M.K./	3,135,717	6/2/64	Gregorian et al.	260	45.5	
	3,786,116	1/15/74	Milkovich et al.	260	885	
	3,832,423	8/27/74	Milkovich et al.	260	878	
	3,862,267	1/21/75	Milkovich et al.	260	878	
	4,007,311	2/8/77	Harlan, Jr.	428	246	
	5,057,366	10/15/91	Husman et al.	428	355	
	4,554,324	11/19/85	Husman et al.	525	301	
/M.K./	6,353,107	3/5/02	Kramer et al.	546	216	
	4,581,429	4/8/86	Solomon et al.	526	220	

FOREIGN PATENT DOCUMENTS

	Document Number	Date	Country	Class	Sub Class	Translation Yes No
/M.K./	DE 19909767	9/16/99	Germany	C07D	211/94	*1
/M.K./	EP 0135280	7/11/84	Europe	C08F	4/00	*2
/M.K./	EP 1170277	1/9/02	Europe	C07C4	5/29	*3

OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)

/M.K./	D. Satas, Handbook of Pressure Sensitive Adhesive Technology, 1989, 2 nd Edition, Van Nostrand Reinhold, New York
/M.K./	T. G. Fox, Bull. Am. Phys. Soc. 1 (1956) 123
/M.K./	Macromolecules, 1995, 28, 7886
/M.K./	Houben-Weyl, Methoden der Organischen Chemie, Vol. E19a, p. 60 ff
/M.K./	Fouassier: "Photoinitiation, Photopolymerization and Photocuring: Fundamentals and Applications", Hanser-Verlag, Munich 1995
/M.K./	Carroy et al. in "Chemistry and Technology of UV and EB Formulation for Coatings, Inks and Paints", Oldring (ed.), 1994, SITA, London
/M.K./	Skelhorne, Electron Beam Processing, in Chemistry and Technology of UV and EB Formulation for Coatings, Inks and Paints, Vol. 1, 1991, SITA, London

EXAMINER: /Mark Kaucher/

DATE CONSIDERED:
10/01/2008

- EXAMINER: Initial if Reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformation and not considered, include copy of this form with next communication to applicant.

*1 Equivalent to US 6,353,107

*2 Equivalent to US 4,581,429

*3 Equivalent to US 4,554,324